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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/523,491	03/10/2000	Jason W. Klaus	UTC 003/9035	4903
75	590 09/22/2004		EXAMINER	
Gary C Cohn PLLC Suite 105			FULLER, ERIC B	
4010 Lake Washington Boulevard NE Kirkland, WA 98033			ART UNIT	PAPER NUMBER
			1762	1762
			DATE MAIL ED: 09/22/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
	09/523,491	KLAUS ET AL.	
Office Action Summary	Examiner	Art Unit	
	Eric B Fuller	1762	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence add	iress
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period we Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ide(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this cor D (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on 16 Ju	ly 2004.		
2a) ☐ This action is FINAL . 2b) ☒ This	action is non-final.		
 Since this application is in condition for allowan closed in accordance with the practice under E. 			merits is
Disposition of Claims			
4)⊠ Claim(s) <u>8-10,13-16 and 20-36</u> is/are pending i	n the application		
4a) Of the above claim(s) <u>25-34</u> is/are withdraw	• •		
5) Claim(s) is/are allowed.			
6) Claim(s) <u>8-10,13-16,20-24,35 and 36</u> is/are reje	ected.		
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/or	election requirement.		
Application Papers			
9) The specification is objected to by the Examiner	•		
10) The drawing(s) filed on is/are: a) acce		Examiner.	
Applicant may not request that any objection to the	•		
Replacement drawing sheet(s) including the correction	on is required if the drawing(s) is obj	ected to. See 37 CFI	R 1.121(d).
11)☐ The oath or declaration is objected to by the Exa	aminer. Note the attached Office	Action or form PT0	D-152.
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. & 119(a).	-(d) or (f)	
a) ☐ All b) ☐ Some * c) ☐ None of:	priority under 00 0.0.0. 3 110(a)	-(u) or (i).	
1. Certified copies of the priority documents	have been received.		
2. Certified copies of the priority documents		on No	
3. Copies of the certified copies of the priori			Stage
application from the International Bureau	(PCT Rule 17.2(a)).		
* See the attached detailed Office action for a list of	of the certified copies not received	d.	
Attachment(s)			
Notice of References Cited (PTO-892)	4) Interview Summary ((PTO-413)	
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da 5) Notice of Informal Pa	te	152\
B) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	6) Other:	atent Application (FTO-	132)

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DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on July 16, 2004 has been entered.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 8, 9, 13-16, 20-23, 35, and 36 are rejected under 35 U.S.C. 102(e) as being anticipated by Kang et al. (US 6,174,809).

Kang teaches a process where an initial sacrificial metal layer is formed on a semiconductor substrate by contacting it with a metal halide and then reducing the metal halide with a SiH₄ gas at temperatures within the applicant's range (column 2,

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lines 8-47). Contacting the reduced surface with additional metal halide then forms the metal layer of interest. The process of depositing sacrificial layers, reducing in SH₄, and then depositing the metal layers is repeated until the desired thickness is achieved (figure 3). The metal may be tungsten and the halide may be fluoride (table 4).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 10 and 24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kang et al. (US 6,174,809), as applied to claims 35 and 36 above, in further view of Pogge (US 5,681,775).

Kang teaches the limitations of claims 35 and 36. The reference fails to teach that the substrate surface comprises hydroxide. However, Pogge teaches that it is well known to hydroxilate the surface of semiconductor wafers in order to increase bonding (column 7, lines 12-20). It would have been obvious at the time the invention was made to a person having ordinary skill in the art to hydroxilate the semiconductor substrate of Kang. By doing so, one would reap the benefits of increasing the bonding of the metal layer with the substrate.

Response to Arguments

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Applicant argues that the amendments of the last response overcome the prior art made of record. Examiner agrees and has withdrawn the rejections of the previous Office Action accordingly. Applicant's arguments are most in view of the grounds of rejection.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eric B Fuller whose telephone number is (571) 272-1420. The examiner can normally be reached on Mondays through Thursdays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Shrive P Beck, can be reached on (571) 272-1415. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

EBF

TIMOTHY MEEKS PRIMARY EXAMINER